

# ELECTROPHYSICAL PROPERTIES OF TRANSITION METALS CHALCOGENIDES STRUCTURES USED AS STRUCTURAL ELEMENTS OF THE NANO-ELECTRONICS DEVICES

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## I. INTRODUCTION

Isolated graphene, which was successfully manufactured, has a zero bandgap [1]. Two-dimensional materials can be used to solve this problem. In our work, the bilayered heterostructures have been studied. The energetic influence of the 2D MoS<sub>2</sub> and WSe<sub>2</sub> on the electrical properties of the graphene has been simulated. Also, electrical properties modified by the effect of an external electric field, so crucial in semiconductor applications, were simulated.

## II. COMPUTATIONAL DETAILS

Our calculations were performed based on the density functional theory (DFT). The projector-augmented wave (PAW) [2] potentials and Perdew–Burke–Ernzerhof (PBE) [3] functional have been used. The exchange–correlation potential was described through the local density approximation (LDA) [4] and Hubbard correction for 3d electrons of Mo and W ( $U = 5$  eV) were employed. A cutoff energy of 480 eV and a  $5 \times 5 \times 1$  k-points grid determined by a fine grid of gamma-centered method [5] in the Brillouin zone. The valence electron configurations for Mo, S, W, Se and C were  $4d^{10}5s^25p^2$ ,  $3s^23p^4$ ,  $5d^{10}6s^26p^2$  and  $5s^25p^5$ , respectively. The heterostructures were built by 3 unit cells of MoS<sub>2</sub> and 4 unit cells of C (MoS<sub>2</sub>/G), also 3 unit cells of WSe<sub>2</sub> and 4 unit cells of C (WSe<sub>2</sub>/G). The atomic structures were relaxed until the forces on all unconstrained atoms were smaller than 0.01 eV/Å. A vacuum layer of 15 Å along z direction was constructed to eliminate the interaction with spurious replica images. The DFT-D3 method of Grimme [6] was used to account for long range vdW interaction between monolayers.

All of the calculations have been carried out using VASP (Vienna Ab-initio Simulation Package) [3, 7] wherein implemented methods described above.

Structural figures and charge density drawings were produced by VESTA package [8].

## III. RESULTS AND DISCUSSION

First of all, the total energy optimization was performed for the unit cell relaxation of the investigated materials. The lattice mismatch of the created heterostructures was about 3.01% for MoS<sub>2</sub>/G and 1.15% for WSe<sub>2</sub>/G. The shape and volume of supercells were considered to be unchangeable at self-consistent calculations. Interlayer distances between sheets of structures have been calculated. Thereby, calculated interlayer distances are 3.50 Å and 3.45 Å for WSe<sub>2</sub>/G and MoS<sub>2</sub>/G respectively (Fig. 1).

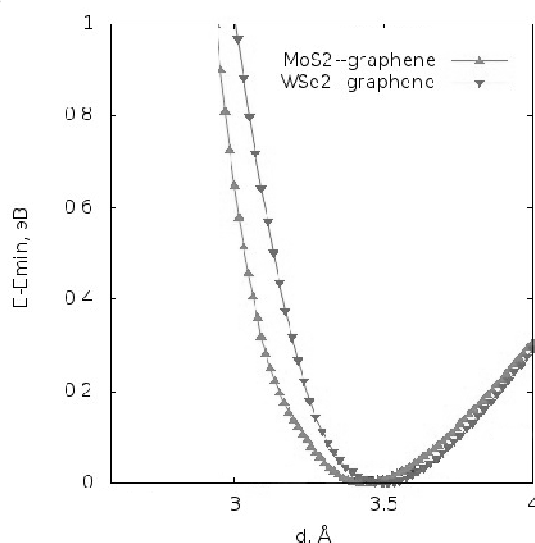


Figure 1 – Interlayer distance of heterostructures

Non-self-consistent calculations have been carried out along the lines between the high symmetry points K- $\Gamma$ -M-K of the first Brillouin zone. Energy dispersion of graphene sheet in heterostructure has similar character to the pristine graphene, i.e. zero band gap remains (Fig. 2.).

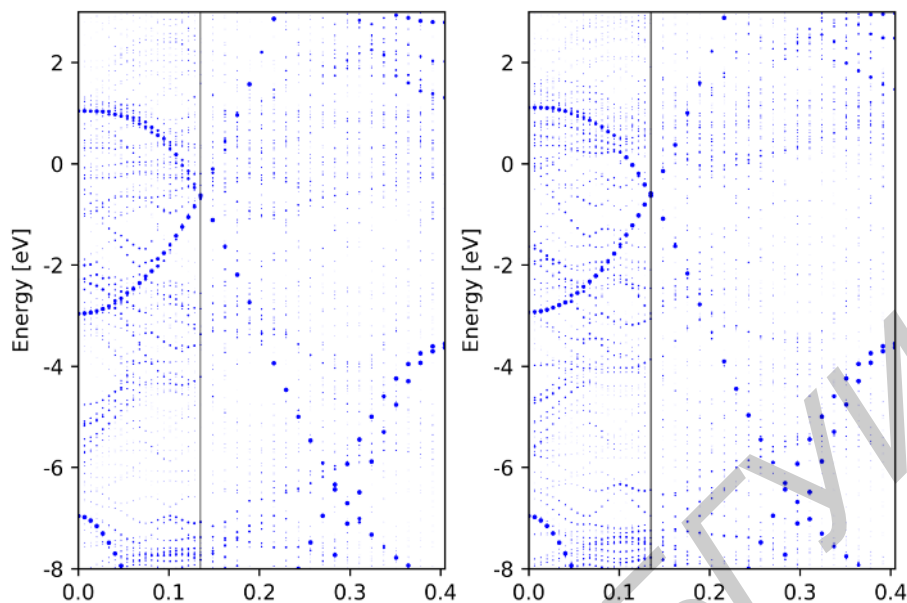


Figure 2 – Band structure of graphene on the MoS<sub>2</sub> substrate (a) and WSe<sub>2</sub> substrate (b)

Vertical electric field has little effect on the bandgap WSe<sub>2</sub>/G and MoS<sub>2</sub>/G. The heterostructures have a direct band gap under influence Efield of 0.15 V/Å. Analysis of the results showed that a vertical external electric field can regulate charge transfer between monolayers and graphene.

### III. CONCLUSIONS

In summary, bilayered heterostructures of WSe<sub>2</sub>/G and MoS<sub>2</sub>/G have been theoretically simulated. Energy dispersion of graphene sheet in heterostructure has similar character to the pristine graphene. Vertical electric field (0.15 V/Å) weakly affects on the bandgap WSe<sub>2</sub>/G and MoS<sub>2</sub>/G and can regulate charge transfer between monolayers and graphene. Utilization of Efield would lead to the realization of electronic properties engineering of the materials.

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### REFERENCES

- [1] K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, Y. Zhang, S. V. Dubonos and A. A. Firsov, *Science*, 2007, 306, 666–669
- [2] G. Kresse and D. Joubert, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1999, 59, 1758–1775
- [3] G. Kresse and J. Furthmüller, *Comput. Mater. Sci.*, 1996, 6, 15–50
- [4] J. P. Perdew, K. Burke and M. Ernzerhof, *Phys. Rev. Lett.*, 1996, 77, 3865
- [5] H. J. Monkhorst and J. D. Pack, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1976, 13, 5188
- [6] S. Grimme, J. Antony, S. Ehrlich and H. Krieg, *J. Chem. Phys.*, 2010, 132, 154104–154119
- [7] P. E. Blöchl, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 1994, 50, 17953–17979
- [8] K. Momma and F. Izumi, *J. Mineral. Petrol. Sci.*, 2010, 39, 136–145